



Patents Form P6

Request for grant of a short-term patent

Patents Ordinance (Cap. 514)

Patents (General) Rules (Cap. 514C)

Important notes

1. General notes:

- a. Either Chinese or English can be used as the language of proceedings. Please complete this form in English unless otherwise stated.
- b. This form must be signed and dated.
- c. If there is not enough space for any part on this form, please continue on an additional sheet. Number each additional sheet and state the number of additional sheet(s) in Part 11(a).
- d. Please enquire through the following means:
 - E-mail: enquiry@ipd.gov.hk
 - Internet homepage address: www.ipd.gov.hk

2. Use of Personal data:

- a. The provision of your personal data is voluntary. However, the Patents Registry may be unable to handle your application, filing request or notice if you do not provide sufficient information.
- b. The Patents Registry will use any personal data provided in this form and any document(s) filed in relation to it for processing your application, request or notice, as well as for the purposes of collection set out at www.ipd.gov.hk/eng/home.htm. **Any of the information provided may be made available for public inspection, in full or in part, pursuant to section 147 of the Patents Ordinance, Cap. 514. Such information may be accessed through the Internet.**
- c. The Patents Registry may redact unsolicited personal data included with this form or any document(s) filed in relation to it before making them available for public inspection. Please **DO NOT provide any personal data (including personal data relating to third parties) which are not specifically required to be submitted.**
- d. Subject to the requirements of the Patents Ordinance, Cap. 514, any person has the right to request access to and correct his/her personal data held in the patent records maintained by the Patents Registry, pursuant to sections 18 and 22 of the Personal Data (Privacy) Ordinance, Cap. 486.
- e. For further details, please see the Personal Information Collection Statement at www.ipd.gov.hk/eng/home.htm.

3. Use of Other Information:

- a. The Patents Registry will use any information relating to any commercial enterprise or entity provided in this form and any document(s) filed in relation to it for processing your application, request or notice, and for the purposes of collection set out at www.ipd.gov.hk/eng/home.htm. **They may be made available for public inspection, in full or in part, pursuant to section 147 of the Patents Ordinance, Cap. 514. Such information may be accessed through the Internet.**
- b. **DO NOT include any business information of your own or that of third parties which you consider to be confidential or commercially sensitive.** Where such information is included in this form or any document(s) filed in relation to it, the Registrar will treat it as an express and voluntary consent given by you and any such third party to disclosure of all such information for the purpose of public inspection.

4. Submission of application/request/notice:

In person or by mail with the appropriate fee to the Registrar of Patents, 24/F, Wu Chung House, No. 213 Queen's Road East, Wanchai, Hong Kong, China. The fee schedule can be viewed at www.ipd.gov.hk/eng/forms_fees.htm. Payment can be made in person by cash, or by sending a cheque made payable to THE GOVERNMENT OF THE HONG KONG SPECIAL ADMINISTRATIVE REGION.

<p>(c) If you have marked "No" in both boxes in (b), please give the following details:</p> <p>Name and address of the depositary institution where a culture of the micro-organism is deposited</p> <p>Date of deposit (DD-MM-YYYY)</p> <p>Accession no. of the deposit</p> <p><i>(section 73 and Schedule 1, Patents (General) Rules, which can be viewed at www.ipd.gov.hk)</i></p>	Name
	Address

<p>05 Details of international application If the short-term patent application is based on</p> <p>(a) International application no.</p> <p>(b) International filing date (DD-MM-YYYY)</p> <p>(c) International publication no.</p> <p>(d) International publication date (DD-MM-YYYY)</p> <p>(e) Date of entry into the national phase in the People's Republic of China</p> <p>or</p> <p>Date of issuance of the National Application Notification by the State Intellectual Property Office, People's Republic of China</p> <p>(f) Application no. of the Chinese patent application <i>(if known)</i></p> <p><i>(section 125, Patents Ordinance and section 78, Patents (General) Rules, which can be viewed at www.ipd.gov.hk)</i></p>	
	<p><i>Please mark the appropriate box and enter the date in the space provided</i></p> <p><input type="checkbox"/> _____ (DD-MM-YYYY)</p> <p><input type="checkbox"/> _____ (DD-MM-YYYY)</p>

Note 2 A claim of earlier application date may be made under:
 (a) section 116, Patents Ordinance for divisional application;
 (b) section 55, Patents Ordinance for new application filed on court order upon determination of right to patent after grant.
 The Patents Ordinance can be viewed at www.ipd.gov.hk.

06 Details of earlier application If the application is divided or derived from an earlier Hong Kong SAR application (Note 2) (a) Section under which an earlier application is claimed (b) Earlier application no. (c) Earlier application filing date (DD-MM-YYYY)	<i>Please mark the appropriate box</i> Patents Ordinance <input type="checkbox"/> Section 116 <input type="checkbox"/> Section 55	

07 Details of priority application If a statement of claim of priority under section 111, Patents Ordinance is made, please provide a statement and details in the space below: <i>(sections 58(5)(c), 69, Patents (General) Rules, which can be viewed at www.ipd.gov.hk)</i>		
Statement		
Country/Territory/Area	Priority application no.	Priority application filing date (DD-MM-YYYY)

Note 3 If the applicant is not the sole inventor or the applicants are not the joint inventors, a statement identifying the inventor(s) and indicating the derivation of the applicant's entitlement to exercise his right to the short-term patent shall be made on Form P6A (section 113(2)(c), Patents Ordinance and section 65, Patents (General) Rules, which can be viewed at www.ipd.gov.hk).

08 Details of inventor <i>(If the name of the inventor is not in Roman letters or in Chinese, please include a transliteration in Roman letters.)</i> (Note 3)
Name
Name in Chinese <i>(if applicable)</i>
Address

Note 4 Please refer to section 109, Patents Ordinance and sections 58(5)(e), 58(5)(f), 70, Patents (General) Rules for claim of non-prejudicial disclosure. The Patents Ordinance and Patents (General) Rules can be viewed at www.ipd.gov.hk.

09 Non-prejudicial disclosure If the applicant is making a claim regarding non-prejudicial disclosure under section 109, Patents Ordinance, please provide a statement giving details relating to such disclosure. <i>(Note 4)</i>	Statement		
	Name and place of the exhibition or meeting	Opening date of the exhibition or meeting <i>(DD-MM-YYYY)</i>	Date of first disclosure <i>(DD-MM-YYYY)</i>

10 If a request for deferral of grant under section 119, Patents Ordinance is required, please mark the box and enter the period of such deferral. The Patents Ordinance can be viewed at www.ipd.gov.hk . <i>(The period of deferral should not exceed 12 months.)</i> <i>(If the box is not marked, it will be taken that deferral of grant is not requested.)</i>	<input type="checkbox"/> Request for deferral of grant up to _____ <i>(DD-MM-YYYY)</i>
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11 Enter the no. of sheet(s) for any of the following documents you are filing with this form	No. of sheet(s)
(a) Additional sheet(s) attached to this form	
(b) Description	
(c) Claim(s)	
(d) Drawing(s)	
(e) Abstract <i>(in both English and Chinese)</i>	
(f) Priority document(s)	
(g) Translation of the priority document(s)	
(h) Search report	
(i) Translation of the search report	

<p>(j) In the case of an international application, copy of :</p> <p>(i) the international application as published by the International Bureau</p> <p>(ii) the international search report</p> <p>(iii) translation as published by the State Intellectual Property Office, People's Republic of China</p> <p>(iv) publication of information by the State Intellectual Property Office, People's Republic of China concerning the international application</p> <p>(k) Statement of inventorship on Form P6A in accordance with section 113(2)(c), Patents Ordinance and section 65, Patents (General) Rules</p> <p>(l) Others (<i>please specify</i>)</p>	

Note 5 An address for service in Hong Kong, China must be supplied.

<p>12 Address for service in Hong Kong, China (<i>Note 5</i>)</p> <p>Name</p> <p>Address</p> <p>Telephone no.</p> <p>Facsimile no.</p> <p>E-mail address</p>	

Note 6 If you are an agent, an address in Hong Kong, China where you reside or carry on your business activities must be supplied.

<p>13 Agent's address (<i>Note 6</i>)</p>	
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14 Signature

I/We confirm that I/we have read and understood the “Important notes” on page 1.

Signature

Name and Official Capacity of Signatory

Date (DD-MM-YYYY)